## Abstract

Field effect transistor with suitable source, drain and channel materials and integrated circuit comprising same

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The normally on transistor comprises a source (10), a drain (11) and a channel (7). The source, drain and channel materials are chosen such that, for a NMOS type transistor, the electronic affinity Xd of the drain material is lower than the electronic affinity Xc of the channel material and the electronic affinity Xs of the source material is higher than the electronic affinity Xc of the channel material (Xd<Xc<Xs). Moreover, the materials are selected such that, for a PMOS type transistor, the upper level Ed of the valence band of the drain material is higher than the upper level Ec of the valence band of the channel material and the upper level Es of the valence band of the source material is lower than the upper level Ec of the valence band of the channel material (Es<Ec<Ed).

(Figure 5)